

**EFFECT OF SUBSTRATE TEMPERATURE ON THE  
ELECTRICAL PROPERTIES OF  
NANOSTRUCTURED ZINC OXIDE THIN FILM  
FOR AMMONIA SENSOR APPLICATION**

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## **ACKNOWLEDGEMENT**

First of all, I would like to express my thankful and grateful to Allah S.W.T for his blessings and kindness as He gives me strength to complete my Final Year Project Report. I always pray for His helpness on day and night to give sufficient times, and spaces so that I could try my best to provide the report for this subject. At the hazard of leaving someone mistaken, I would like to thank the following respective individuals for their big contribution and guide towards in accomplishing this project.

First and foremost, I would like to thank my supervisor, Assoc. Prof. Dr. Mohamad Rusop Mahmood and my tutor, Pn Samsiah Ahmad for his patience and guidance throughout the whole year for the completion my Final Year Project (FYP). I would also like to thank my family members for always being there to support me all the time and give me the courage and strength that are necessary for me to carry on with this project.

Last but not least, I would like to thank all the lecturers that have taught me throughout my education in Universiti Teknologi MARA, and also to my fellow friends in campus and hometown. Today I learned something that could be very valuable for me in future.

## **ABSTRACT**

This project focuses on the effect of substrate temperature on the electrical properties of nanostructured zinc oxide thin film for the ammonia sensor application. Nanostructured zinc oxide thin film has been deposited on the thermally oxidized SiO<sub>2</sub> using radio frequency (RF) magnetron sputtering at various temperatures range from room temperature to 500°C. The thickness of the thin film was measured using surface profiler. The surface morphology and grain size were measured using field emission scanning electron microscopy (FESEM). The grain size were increased with the increased of substrate temperature. The effect of substrate temperature on the electrical properties and sensitivity has been investigated. The highest percentage of sensitivity is at room temperature that is 94.5%.

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# **CHAPTER 1**

## **INTRODUCTION**

### **1.1 NANOTECHNOLOGY**

Nowadays, the scientists around the world have given more attentions on nanotechnology. Nanotechnology introduced new dimension to science and technology with the possibilities of manipulating atoms and molecules at the nanometer level. With nanotechnology, the application are more advance and effects of various technological domains including advance materials, biotechnology and pharmacy, scientific tools, industrial process and electronic field [1].

In new trend, scientists and researchers has aggressively got involved in the nanotechnology field through academic research and corporation directing their Research and Development activities to explore in nanotechnology field opportunities. The nanotechnology field was enabling the development of technology in instrumentation which is start to manipulating the atomic or molecular scale of nanostructure. This technology also offered industrial to create new nanoproducts with enhancement of the performance parameters of electronic, food, biological and others industries [1].